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## PATENT 30205/39513

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Young Sun Hwang et al.	<ul> <li>I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on January 13,</li> <li>2006, in an envelope addressed to MS</li> <li>Amendments, Commissioner for Patents,</li> <li>P.O. Box 1450, Alexandria, Virginia 22313-1450</li> </ul>
Serial No.: 10/719,083	
Filed: November 21, 2003	
For: Methods for Forming Fine Photoresist Patterns	
Group Art Unit: 1765	)
Examiner: Patricia Ann George	) \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \
Confirmation No. 2261	James P. Zelled Reg. No. 28,491 Attorney for Applicant

**AMENDMENT "A"** 

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

## Dear Sirs:

Please amend this application as follows:

the amendment to the claims section (along with a complete listing of claims) begins on page 2 of this paper;

the remarks section begins on page 4 of this paper.